

IDS Form PTO/SB/08: Substitute for form 1449A/PTO				Complete If Known	
				Application Number	10/814,335
				Filing Date	April 1, 2004
				First Named Inventor	Grégory PLOS
				Art Unit	1751
				Examiner Name	E. Elhilo
Sheet	3	of	15	Attorney Docket Number	05725.1314-00000

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EE	61	US 4,719,282	01/12/1988	Nadolsky et al.	
	62	US 4,728,571	03/01/1988	Clemens et al.	
	63	US 4,781,273	08/02/1988	Grollier et al.	
	64	US 4,781,724	11/01/1988	Wajaroff et al.	
	65	US 4,823,985	04/25/1989	Grollier et al.	
	66	US 4,839,166	06/13/1989	Grollier et al.	
	67	US 4,948,579	08/14/1990	Jacquet et al.	
	68	US 4,961,925	10/09/1990	Tsujino et al.	
	69	US 4,972,037	11/20/1990	Garbe et al.	
	70	US 4,996,059	02/26/1991	Grollier et al.	
	71	US 5,009,880	04/23/1991	Grollier et al.	
	72	US 5,057,311	10/15/1991	Hanazawa et al.	Kamegai et al.
	73	US 5,089,252	02/18/1992	Grollier et al.	
	74	US 5,139,037	08/18/1992	Grollier et al.	
	75	US 5,188,639	02/23/1993	Schultz et al.	
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	77	US 5,275,808	01/14/1994	De Groot et al.	Murray et al!
	78	US 5,356,438	10/18/1994	Kim et al.	
	79	US 5,445,655	08/29/1995	Kuhn et al.	
	80	US 5,635,461	06/03/1997	Onitsuka et al.	
	81	US 5,708,151	01/13/1998	Möckli	
	82	US 5,733,343	03/31/1998	Mockli	
	83	US 5,744,127	04/28/1998	Giuseppe et al.	
	84	US 5,792,221	08/11/1998	Lagrange et al.	
	85	US 5,830,446	11/03/1998	Berthiaume et al.	
	86	US 5,833,997	11/10/1998	Mahieu et al.	
	87	US 5,853,708	12/29/1998	Cauwet et al.	
	88	US 5,873,494	02/23/1999	Dallas, Jr.	
	89	US 5,958,392	09/28/1999	Grollier et al.	
EE	90	US 5,962,522	10/05/1999	Wacher et al.	
EE	91	US 6,106,577	08/22/2000	Audouset et al.	

Examiner Signature	/Eisa Elhilo/	Date Considered	11/10/2006
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 809. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.